Electronic Supplementary Information (ESI)

## Facile Solvothermal Synthesis and Superior Lithium Storage Capability of Co<sub>3</sub>O<sub>4</sub> Nanoflowers with Multi-scale Dimensions

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Fig. S1: Typical FE-SEM images of  $Co_3O_4$  -MF precursors synthesized with 8 mL  $NH_3$  in solvothermal synthesis



**Fig. S2**: Typical FE-SEM images of precursors synthesized with  $NH_3$  of 12 mL and 2 mL in solvothermal synthesis (a,b) 12 mL  $NH_3$ ; (c,d) 2 mL  $NH_3$ 



Fig. S3: pH values of reactant solution as a function of added ammonia before and after solvothermal treatment



Fig. S4: XRD patterns of flower-like precursors (Co<sub>3</sub>O<sub>4</sub>-NF and Co<sub>3</sub>O<sub>4</sub>-MF)





Fig. S5: TGA curve of Co<sub>3</sub>O<sub>4</sub>-NF products tested with a heating rate of 10°C min<sup>-1</sup>



Fig. S6: High resolution N1s spectra of Co<sub>3</sub>O<sub>4</sub>-NF precursors and products



Fig. S7: FE-SEM image of commercial Co<sub>3</sub>O<sub>4</sub> micro-/nanoparticles (Co<sub>3</sub>O<sub>4</sub>-NP)



**Fig. S8:** Typical FE-SEM images of  $Co_3O_4$ -NF after electrochemical measurement at a current density of 500 mAh g<sup>-1</sup> for 100 cycles



**Fig. S9:** C-rate performance of commercial Co<sub>3</sub>O<sub>4</sub> with micro-/nanoparticles (Co<sub>3</sub>O<sub>4</sub>-NP) under different current densities



Table S1: Specific surface areas, pore size distributions and pore sizes of  $Co_3O_4$ -NF and  $Co_3O_4$ -MF

Sample name	Specific surface area	Pore volume	Average pore size		
	$(m^2 g^{-1})$	$(cm^3 g^{-1})$	(nm)		
Co <sub>3</sub> O <sub>4</sub> -NF	103.9	0.587	22.6		
Co <sub>3</sub> O <sub>4</sub> -MF	83.6	0.308	N.A.		

Co <sub>3</sub> O <sub>4</sub> material morphologies	Specific surface area (m <sup>2</sup> g <sup>-1</sup> )	Average pore size (nm)	Current density (mA g <sup>-1</sup> )	First discharge/ charge capacity (mAh g <sup>-1</sup> )	Coulombic efficiency	Cycling number	Discharge capacity after cycling (mAh g <sup>-1</sup> )	Capacity retention	References
Nanoflowers	103.9	22.6	500	1311.6 /992.3	75.6%	100	1323	~100%	This work
Microflowers	83.6	N.A.	500	1160.9 /876.6	75.5%	100	1281	~110%	This work
Nanoflowers	51.2	12.6	50	1849/1196	64.7%	30	~980	53%	[1]
Flower-like spheres	72.5	4.6	50	1316.7/899.1	68.3%	20	~250	~19%	[2]
Nanobundles	26.4	22.0	100	1670.8/1341	80.3%	60	1667.6	99.8%	[3]
Nanocages	110.6	10	500	975/786	80.6%	100	810	83%	[4]
Nanowire arrays	20.2	8	100	1732/1081	62.4%	70	~550	~69%	[5]
Microdisks	108.9	9.7	100	1032/776	75.2%	30	765	~100%	[6]
Mesoporous octahedra	48.5	9	200	1567/~1176	~75%	60	1178	~75%	[7]
Hollow microspheres	12.8	5~7	178	1298/991.7	76.4%	50	1441.1	111%	[8]
Pompon-like spheres	29.5	17	50	1552/1169	75%	30	~1000	~64%	[9]
Nanobelts	36.5	29.2	100	1204/N.A.	N.A.	60	980	~81%	[10]

**Table S2**: Comparison of material characteristics and electrochemical performances with various structured Co<sub>3</sub>O<sub>4</sub> materials

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